

Title (en)

METHOD FOR PRODUCING RELIEF PATTERNED BODY, DEVICE FOR PRODUCING SAME, AND STICKER

Title (de)

VERFAHREN ZUR HERSTELLUNG EINES RELIEFGEMUSTERTEN KÖRPERS, VERFAHREN ZUR HERSTELLUNG DAVON UND AUFKLEBER

Title (fr)

PROCÉDÉ DE PRODUCTION D'UN CORPS À MOTIF EN RELIEF, DISPOSITIF DE PRODUCTION ASSOCIÉ ET AUTOCOLLANT

Publication

EP 3297019 A1 20180321 (EN)

Application

EP 16792556 A 20160426

Priority

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Abstract (en)

Provided are a method and an apparatus for producing a relief-pattern body, the method and apparatus being suitable for producing a film-like material, such as an embossed film, having a fine relief-structure pattern formed on a surface thereof so as to have a distinctive optical effect with high quality, good productivity, and fewer defects. A transfer pattern printed layer (22) having an inverted structure of a relief-structure pattern is formed on a second substrate (23) by printing a transfer pattern onto the surface of a first substrate (21) on which the relief-structure pattern is formed at a predetermined position by registration with the relief-structure pattern followed by drying, laminating with the second substrate (23), curing and peeling.

IPC 8 full level

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